Inventor: Demetrius Sarigiannis, Garo J. Derderian and Cem Basceri

Title: Methods of Forming Layers Over Substrates; and Methods

of Forming Trenched Isolation Regions

Assignee: Micron Technology, Inc.

INFORMATION DISCLOSURE STATEMENT PURSUANT TO 37 C.F.R. §§ 1.56, 1.97 AND 1.98

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, the Examiner's attention is directed to the references listed on the attached Form PTO-1449 and copies of which are attached. No admission is made regarding whether all the submitted references are prior art.

Citation of these references is respectfully requested.

Date: 6/26/2003 Attorney: Am

David G. Latwesen, Ph.D.

Reg. No. 38,533 Wells, St. John P.S.

Form PTO-1449				ATTY. DOCKET N MI22-2264	SERIAL NO. Filed herewith						
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)						APPLICANT Micron Technology, Inc.					
						FILING DATE Filed herewith			GROUP Unknown		
					U.S. PATENT DOCUMENTS						
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				OTHER REFE	RENCES (including Author, Title, Date,	Pertinent Pages, Etc.)	-	-			-
	АН		"Atomic Layer Deposition of SiO ₂ Using Catalyzed And Uncatalyzed Self-Limiting Surface Reactions", J.W. Klaus et al; Surface Review								al;
			and Letters, Vol. 6, Nos. 3 & 4 (1999) pp. 435-448								
	AI		Self-limiting chemical vapor deposition of an ultra-thin silicon oxide film using tri-(tert-butoxy)silanol*, K.A., Miller								et al;
<u> </u>			Thin Solid Films 397 (2001; pp. 78-82)								
 -	AJ		"Reactive Deposition of Metal Thin Films within Porous Supports from Supercritical Fluids", Neil E. Fernandes Mater. 2001;								l.; Chem
		13, pp. 2023-2031									
	AK	AK *Supercritical CO ₂ Processing for Submicron Imagine of Fluoropolymers*, Narayan Sundararajan et al; Chem. Mater. 2 12;									
		pg. 41-48									
	AL	"Supercritical carbon dioxide assisted aerosolization for thin film deposition, fine powder generation, and drug deliv									very":
			C.Y. Xu et al.; P.T. Anastas; T.C. Williamson, Green Chemistry, 5. pp. 313-335; Oxford University Press, Oxford 1998								
	АМ		*Supercritical Fluid Transport-Chemical Deposition of Films*. Brian N. Hansen et al.; Chem Mater. 1992; 4; pp. 749-752								

EXAMINER				DATE CONSIDERE	ED .						
			considered, whether on to applicant		in conformance with MPEP 609; Dra	w line through citation	if not in conf	ormano	e and n	ot considered.	Include